

Program at a Glance

Time	Sunday, October 14, 2018	Monday, October 15, 2018			Tuesday, October 16, 2018			Wednesday, October 17, 2018			Thursday, October 18, 2018
		Room 1 Main Hall	Room 2 Reception Hall B	Room 3 301	Room 1 Main Hall	Room 2 Reception Hall B	Room 3 301	Room 1 Main Hall	Room 2 Reception Hall B	Room 3 301	
9:00		Registration			9:00-9:40 Plenary 3 Prof. Brian Thomas			9:00-9:40 Plenary 5 Prof. Engang Wang			Excursion
		9:30-9:50 Opening Address									
10:00		9:50-10:30 Plenary 1 Prof. Yves Fautrelle			9:40-10:20 Plenary 4 Dr. Yuji Miki			9:40-10:20 Plenary 6 Prof. Kazuhiko Iwai			
		10:30-11:10 Plenary 2 Prof. Zhongming Ren			10:20-10:40 Coffee Break			10:20-10:40 Coffee Break			
11:00			11:10-11:20 Photo		10:40-12:10 Electromagnetic Melting 2	10:40-12:20 Microwaves 1	10:40-12:10 Advanced Materials Processing 1	10:40-12:10 Solidification, Crystal Growth 4	10:40-12:10 Induction Heating 1	10:40-11:10 Low Electrical Conductivity Liquid Processing 1 11:10-12:00 Recycling 1	
12:00		11:20-13:10 Lunch						12:10-14:00 Lunch			
13:00		13:10-15:10 EM Shaping, Forming, Levitation 1	13:10-14:40 Solidification, Crystal Growth 1	13:10-15:10 Electromagnetic Melting 1	12:20-14:10 Lunch						
14:00					14:10-16:20 Solidification, Crystal Growth 2	14:10-15:20 Fundamental of EPM 1	14:10-14:50 Advanced Materials Processing 2 14:50-16:10 EM Processes 2	14:00-15:50 Solidification, Crystal Growth 5	14:00-15:20 EM Treatment 1	14:00-15:50 Fundamental of EPM 3	
15:00		15:10-15:40 Coffee Break							15:20-16:20 Advanced Materials Processing 3		
16:00		15:40-17:20 Measurement Technique 1	15:40-17:20 Melt Flow Control 1	15:40-17:50 EM Processes 1							
					16:20-16:40 Coffee Break						
17:00	16:30-17:30 Poster Set-up 17:00- Registration	17:20-18:00 EM Shaping, Forming, Levitation 2			16:40-18:30 Solidification, Crystal Growth 3	16:40-18:30 Fundamental of EPM 2		16:20-18:00 Poster Session			
18:00	18:00- Welcome Reception							18:00-18:20 Poster Removal 18:20-19:00 Break			
19:00								19:00- Banquet			